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Influences of cracking of coated superconducting layer on voltage-current curve, critical current, and \( n \)-value in DyBCO-coated conductor pulled in tension


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Influences of cracking of coating layer under applied tensile strain on \( V \)(voltage)-\( I \)(current) curve, critical current, and \( n \)-value of \( \text{ReBa}_2\text{Cu}_3\text{O}_{7-\delta} \) coated conductor were studied experimentally and analytically. The experimentally measured variations in \( V-I \) curve, critical current, and \( n \)-value with increasing applied strain and the correlation of \( n \)-value to critical current were described well by the partial crack-current shunting model of Fang et al. Also, the variations in the ratio of shunting current to overall critical current and the ratio of voltage developed in the cracked region to overall voltage with extension of crack, and the variation in critical current with the ratio of noncracked area to overall cross-sectional area of superconducting layer were revealed. © 2010 American Institute of Physics. [doi:10.1063/1.3488014]

I. INTRODUCTION

\( \text{Re(Y,Sm,Dy)Ba}_2\text{Cu}_3\text{O}_{7-\delta} \) coated conductors with long length and high critical current have been developed and are expected for wide application such as power cables, fault current limiters and current leads. In fabrication and service, they are, more or less, subjected to thermal, mechanical, and electromagnetic stresses/strains. Concerning the influence of subjected strain on critical current of coated conductors, it has been revealed that the critical current is reversible up to the irreversible strain at which cracking occurs in the \( \text{ReBa}_2\text{Cu}_3\text{O}_{7-\delta} \) layer but beyond the irreversible strain, the critical current decreases with increasing applied strain due to the extension of cracking. It is required to reveal the relation of cracking to superconducting properties for safe and reliability in application. In the present work, we studied the influence of cracking of the superconducting layer on the critical current and \( n \)-value in the \( \text{DyBa}_2\text{Cu}_3\text{O}_{7-\delta} \) (DyBCO) coated conductor with MgO buffer layer deposited on the Hastelloy C-276 substrate by inclined substrate deposition (ISD), prepared at THEVA, Germany. Compared to YBCO, DyBCO has the advantages of a better chemical stability and more resistance to corrosive ambient, a slightly higher transition temperature, and a lower surface resistance at 77 K.

The as-supplied conductor had been coated with a thin Ag layer of 0.5 \( \mu \)m to solder the voltage taps for measurement of \( V \)(voltage)-\( I \)(current) curve and critical current under no applied strain. Sugano et al. have revealed, when the Hastelloy C-276 is exposed at the deposition temperature (963 K in this case), discontinuous yielding takes place similarly to the Lüders band extension under applied strain, causing arrayed multiple cracking of the coated layer and hence causing reduction in critical current. An example of the arrayed multiple cracking in the DyBCO layer, observed in the present sample is shown in Fig. 1. The cracks are small in the initial stage of multiple cracking but it extends in transverse direction with increasing applied strain. Sugano et al. have also found that quenching occurs after several percent-reduction in critical current, due to the progress of multiple cracking and small thickness of Ag layer. This premature quenching makes it difficult to measure the strain-dependence of critical current in wide strain range that covers the variation in critical current from the original value to zero.

In the present work, copper was electroplated onto the sample in order to give a shunting circuit that acts when the imposed current encounters the cracks. With copper plating,
the change in critical current from the original value to zero with increasing applied tensile strain could be measured successfully. The measured changes in $V$-$I$ curve, critical current $I_c$, and $n$-value with increasing applied strain and the obtained correlation of $n$-value to critical current are shown in Sec. III. The experimental results were analyzed by the model of Fang et al. The outline of the model is shown in Sec. IV. The result of the analysis is shown in Sec. V. It is shown that the experimental results are described well by this model. Also the variations in critical current, shunting current, and voltage developed in the cracked region with extension of crack are discussed.

II. EXPERIMENTAL DETAILS

A. Sample

The DyBCO coated conductor prepared by THEVA was used for the present experiment and analysis. The fabrication procedure has been shown elsewhere. The sample consisted of Hastelloy C276 substrate (thickness $90 \mu m$), MgO buffer layer ($3.3 \mu m$) deposited by ISD process, MgO cap layer ($0.3 \mu m$), DyBCO superconducting layer ($2.5 \mu m$), and Ag contact layer ($0.5 \mu m$). The width of the conductor was $10 mm$. Due to the reason mentioned in Sec. I, copper was electroplated onto the sample at room temperature with an electrolyte composed of $CuSO_4$:210 g/l, $H_2SO_4$:52.4 g/l and pure water. The thickness of the plated copper layer was $35 \mu m$.

B. Measurement of $V$-$I$ curve, critical current $I_c$, and $n$-value of copper plated-sample under applied tensile strain

Tensile strain was applied to the sample at $77 K$ with an Instron type testing machine. The sample was gripped by copper chucks, which also worked as current electrodes during measurement of critical current. To reduce the stress concentration within and near the chucks, Indium foils were inserted between the sample and chucks. For measurement of strain of the sample, a couple of very light Nyilas type extensometers were attached directly to the sample.

The voltage taps for measurement of the $V$-$I$ curves were soldered with a spacing of $45 mm$. The $V$-$I$ curves under various applied strains were measured with the usual four-probe method at $77 K$ under a self magnetic field. The $V$-$I$ curve was approximated by

$$V = AI^n,$$

where $n$ and $A$ are the fitting constants. The $n$-value was estimated for the voltage range of $V=0.1–10 \mu V/cm$. The critical current $I_c$ was estimated with a criterion of $1 \mu V/cm$.

III. MEASURED $V$-$I$ CURVES, CRITICAL CURRENT $I_c$, AND $N$-VALUES UNDER APPLIED TENSILE STRAIN

Figure 2(a) shows the change in measured critical current $I_c$ and $n$-value with increasing applied tensile strain $\varepsilon_T$. The correlation of $n$-value to critical current $I_c$ is shown in Fig. 2(b). Both $I_c$ and $n$-value decreased significantly at high $\varepsilon_T$ [Fig. 2(a)] due to the cracking of the DyBCO layer (Fig. 1). The lower the $I_c$, the lower became the $n$-value [Fig. 2(b)].

The variation $I_c$ as a function of $\varepsilon_T$ in the reversible strain range has been investigated for wide variety of Re(Y, Sm, Dy)BCO samples. The reported results show that the shape of $I_c - \varepsilon_T$ curve is dependent on the species of Re(Y, Dy, Sm), fabrication process and microstructure, residual strain and so on. Concerning the present DyBCO sample in the as-supplied state (without copper plating), it has been shown that $I_c$ decreases almost linearly.

Fig. 3 shows the change in (a) critical current $I_c$ and (b) $n$-value with increasing applied tensile strain $\varepsilon_T$ in low tensile strain range.
ing \( \epsilon_T \) in low tensile strain range of the present copper-plated DyBCO sample. In Fig. 3(a), \( I_c \) decreased almost linearly with \( \epsilon_T \) in the tensile strain range of 0.1\% < \( \epsilon_T < 0.324\% \) and it decreased sharply at the next strain \( \epsilon_T = 0.345\% \). In Fig. 3(b), the change in \( n \)-value with \( \epsilon_T \) up to \( \epsilon_T = 0.324\% \) was minor in comparison with the sharp decrease at \( \epsilon_T = 0.345\% \). These results suggest that the irreversible tensile strain, \( \epsilon_{T, irr} \), existed between 0.324\% and 0.345\%, as indicated in Fig. 3(a). The sharp decreases in \( I_c \) and \( n \)-value beyond \( \epsilon_T = 0.324\% \) stem from cracking in the DyBCO layer. The ranges of \( \epsilon_T \) in noncracked and cracked states in the present copper-plated sample are shown in Fig. 3(a) and 3(b).

A monotonic decrease in \( I_c \) with \( \epsilon_T \) was found in the strain range of around 0.1\% < \( \epsilon_T < 0.324\% \) in the present sample. Hereafter, we focus on the strain range of 0.1\% < \( \epsilon_T \). The strain dependence of critical current \( I_{c0} \) in noncracked range of 0.1\% < \( \epsilon_T < 0.324\% \) was approximated by

\[
I_{c0} = 199.9 - 15.20 \epsilon_T. \tag{2}
\]

The strain dependence of \( n \)-value in the noncracked range was not large as in Fig. 3(b). Thus, the \( n \)-value in noncracked range was given by the average of the \( n \)-values measured in this range, \( n_0 = 39.6 \). The \( I_{c0} \) given by Eq. (2) and \( n_0 = 39.6 \) are used for analysis of the experimental results of \( V-I \) curve, \( I_c \), and \( n \)-value in Secs. IV and V.

Figure 4 shows representative examples of the measured \( V-I \) curves in (a) normal and (b) logarithmic scale. The Open circles show the experimental results. The \( V-I \) curve measured at \( \epsilon_T = 0.324\% \) refers to noncracked state and the \( V-I \) curves measured at other strains refer to cracked-state. Solid curves show the calculation results with the model of Fang et al.,\textsuperscript{17} whose outline is shown below.

### IV. MODEL USED FOR ANALYSIS

The influence of shunting of current under an existent partial crack in a \( \text{Bi}_2\text{Sr}_2\text{Ca}_2\text{Cu}_3\text{O}_{10+\delta} \) (BSCCO) filament embedded in stabilizer on the \( V-I \) relation has been modeled by Fang et al.\textsuperscript{17} Here, “partial crack” means the crack that exists in a part of transverse cross-section of the superconducting filament. Shin et al.\textsuperscript{19} have applied this model to the measured \( V-I \) curves of the BSCCO filamentary composite tape under applied tensile strain. They found that the measured \( V-I \) curves and change in \( I_c \) as a function of \( \epsilon_T \) can be described with this model by using an effective relative crack size (ratio of the cracked cross-sectional area to overall transverse cross-sectional area). Miyoshi et al.\textsuperscript{20} have applied this model to the \( V-I \) curves of the \( \text{Nb}_3\text{Sn} \) filamentary composite tape containing collective cracks (cracks composed of successively fractured filaments in a transverse cross-section). They found a linear relationship between the relative size of the collective crack and crack density and found that this model captures the effect of diminishing \( I_c \) as a function of fractional decrease in the number of intact filaments. In the present work, we use this model, originally proposed to analyze the influence of a partial crack in a BSCCO filament, for analysis of \( V-I \) curve and for estimation of critical current \( I_c \) and \( n \)-value in the present coated conductor, since the shunting mechanism under existent cracks is common in both filamentary and coated conductors despite the difference in geometry.

In the present sample, the stabilizer contact to DyBCO layer is composed of silver (0.5 \( \mu \text{m} \) in thickness) and plated copper (35 \( \mu \text{m} \) layers). Figure 5 shows a schematic representation of (a) current path, (b) electrical circuit, and (c) simplified electrical circuit under an existent partial crack in DyBCO layer. In the transverse cross-section in which a partial crack exists [Fig. 5(a)], the cracked part losing superconductivity and noncracked part keeping superconductivity co-exist. We define the ratio of cross-sectional area of cracked part to overall cross-sectional area of DyBCO layer as \( f \). The noncracked part with an area ratio 1−\( f \) transports current \( I_d \) through DyBCO layer [Fig. 5(b)]. At the cracked part with an area ratio \( f \), current \( I_c = (1-f)I_d \) shunts into Ag and Cu layers [Fig. 5(b)]. In the shunting circuit in Fig. 5(b), the \( R_{e1} \) and \( R_{e2} \) refer to the resistances at the DyBCO–Ag and Ag–Cu interfaces, respectively, and \( R_{Ag} \) and \( R_{Cu} \) to the resistances in Ag and Cu, respectively. The shunting currents that go through Ag and Cu are noted as \( I_{Ag} \) and \( I_{Cu} \), respectively. The total shunting current \( I_s \) is the sum of \( I_{Ag} \) and \( I_{Cu} \). In (c), the total resistance in the shunting circuit in (b) is replaced by \( R_t \). The voltage developed in the noncracked part that transports current \( I_d \) is noted as \( V_d \) in (b) and (c). The voltage \( V_d = I_dR_t \) developed in the cracked part by shunting current \( I_s \) is equal to \( V_d \) in (c) since the noncracked and cracked parts constitutes of a parallel circuit.

The \( V-I \) relation of noncracked DyBCO layer with a critical current \( I_{c0} \) given by Eq. (2) is expressed as
The overall voltage influence of substituting partially cracked cross-section is expressed as

\[ V = E_c L \left( \frac{I}{I_{c0}} \right)^{n_0} + V_d. \]  

(6)

In application of this model to the present experimental result, the arrayed cracks (Fig. 1) were treated as a single equivalent crack, since the shunting of current occurs in the same mechanism in both single and multiple cracks. Accordingly, the values of \( f \) and \( R_t \) obtained by fitting Eqs. (5) and (6) with the measured \( V-I \) curves correspond to the total effect of multiple cracks. As shown in Sec. V below, the experimental results are described well by the replacement of multiple cracks by a single equivalent crack, indicating that the present approach is useful for analysis of arrayed cracks with complex geometry that appear in most coated conductors especially at high applied strain.

V. RESULT OF ANALYSIS AND ITS COMPARISON WITH EXPERIMENTAL RESULTS

A. Obtained values of \( 1-f \) and \( R_t \), and comparison of the calculated \( V-I \) curves, \( I_c \), and \( n \)-values with experimental results

As the cracking occurred beyond \( \varepsilon_T \approx 0.324\% \), it was impossible to measure the critical current \( I_{c0} \) and \( n_0 \)-value under no crack for \( 0.324\% < \varepsilon_T \). As an approximation, the \( I_{c0} \) value obtained by the extrapolation of Eq. (2) to each tested \( \varepsilon_T \) (\( >0.324\% \)) was used for analysis. \( n_0 \)-value beyond \( \varepsilon_T = 0.324\% \) was taken to be 39.6 (Fig. 3). Substituting \( L = 45 \text{ mm}, s = 0.1 \text{ \mu m}, n_0 = 39.6, \) and \( I_{c0} \) [obtained by substituting the corresponding \( \varepsilon_T \) into Eq. (2)] into Eqs. (5) and (6), and fitting the experimentally measured \( V-I \) curve (Fig. 4) with Eqs. (5) and (6), we had the ratio \( 1-f \) of noncracked area to overall cross-sectional area of DyBCO layer and the resistance \( R_t \) in the cracked range of \( 0.324\% < \varepsilon_T \). The \( 1-f \) was taken to be unity in the noncracked range of 0.1% \( < \varepsilon_T < 0.324\% \). The obtained values of \( 1-f \) and \( R_t \) are plotted against applied tensile strain \( \varepsilon_T \) in Fig. 6. In the cracked range of \( 0.324\% < \varepsilon_T \), the \( 1-f \) decreased from unity to almost zero and the \( R_t \) tended to increase with \( \varepsilon_T \) due to the crack extension.

The obtained values of \( 1-f \) and \( R_t \) were substituted into Eqs. (5) and (6), and the \( V-I \) curve at each \( \varepsilon_T \) back-calculated. Examples of the calculated \( V-I \) curves are shown in Fig. 4. The experimental results are described well, as expected. From the calculated \( V-I \) curve with the estimated \( 1-f \) and \( R_t \) values, the critical current \( I_c \) under 1 \text{ \mu V/cm} criterion and \( n \)-value in the voltage range of 0.1–10 \text{ \mu V/cm} were calculated. Figure 7 shows the comparison of the experimental results (open circles) with the calculation results (open triangles) for (a) critical current \( I_c \), (b) \( n \)-value, and (c) correlation between \( n \)-value to \( I_c \). The experimental results are well described by the calculation results. As stated in Sec. IV, in application of the model of Fang et al.\textsuperscript{17} to the present experimental result, the arrayed cracks (Fig. 1) were treated as a single equivalent crack. The good agreement of calculation results with experimental results for \( V-I \) curves,
B. Shunting current $I_s$ and voltage $V_s(V=V_c)$ developed in the cracked region at $I=I_c$

Figure 8(a) shows an example of the measured and analyzed $V-I$ curve and variation in shunting current $I_s$ with overall current $I$. In this example, the data at $\varepsilon_T=0.411\%$ is picked up representatively. The values of $1-f$ and $R_e$, obtained by fitting Eqs. (5) and (6) to the measured $V-I$ relation, were $0.451$ μΩ and $3.89$ μΩ, respectively. The $V-I$ curve back-calculated by Eqs. (5) and (6) with the obtained values of $1-f$ and $R_e$ is shown with a solid curve. The shunting current $I_s$ as a function of overall current $I$, calculated by $V_s(V=V_c)/R_e$, is shown with a broken curve. The part indicated as (b) in Fig. 8(a) is shown in Fig. 8(b) at high magnification. The critical current $I_c$ for the present voltage probe distance $L=45$ mm is defined at $V=V_c=4.5$ μV under the 1 μV/cm criterion. $I_s$ increases with increasing overall current $I$, especially beyond $I=I_c$. The measured critical current, $I_{c,\text{meas}}$, was 122.4 A. The calculated critical current at $V=V_c=4.5$ μV was 122.1 A, which is very close to the measured value of 122.4 A. As shown in this example and as has been shown in Fig. 7, the difference between the calculated and measured $I_s$ value at each $\varepsilon_T$ was almost within 1 A. The calculated shunting current $I_s$ at the calculated $I_c$ at $V=V_c$ was 1.2 A. The ratio of $I_s$ to $I_c$ at $V=V_c$, $I_s/I_c$, was 0.01 in this example. In the same way, the $I_s/I_c$ at $V=V_c$ at each measured $\varepsilon_T$ was calculated and plotted against calculated $I_c$, as shown in Fig. 8(c). In the wide range of $I_c$ (20–195 A, where 195 A is the critical current $I_c$ at $\varepsilon_T=0.324\%$ just before the occurrence of cracking), the $I_s/I_c$ was less than 0.05. This result indicates that most of the current (more than 95% of the imposed current) is transported by DyBCO layer at $I=I_c$ in the wide range of $I_c$ values.

Figure 9(a) shows also examples of variation in overall voltage $V$ and voltage at cracked part $V_{s,\text{cal}}(V=V_c)$ with overall current $I$, from which the value of $V_{s,\text{cal}}$ at $I=I_c$ ($V=V_c=4.5$ μV), is read. In these examples, the calculated values of $V_{s,\text{cal}}$ were 3.42 μV and 4.50 μV at $\varepsilon_T=0.359\%$ and 0.411%, respectively. The ratios of $V_{s,\text{cal}}$ developed at cracked part to overall voltage $V_c$ (4.5 μV) at $I=I_c$ ($V=V_c=4.5$ μV) were 0.76 and 1.00 at $\varepsilon_T=0.359\%$ and 0.411%, respectively. In the same way, the $V_{s,\text{cal}}/V_c$ at $I=I_c$ at each $\varepsilon_T$ was calculated and plotted against calculated $I_c$, as shown in Fig. 9(b). In the wide range of $I_c$ (20–180 A), corresponding to the range of $0.359\%<\varepsilon_T$, the value of $V_{s,\text{cal}}/V_c$ was 1.00. This result shows that the overall voltage at $I=I_c$ in the cracked sample stems mostly from the cracked region.

The results in Figs. 8 and 9 show that, at $I=I_c$, most of the imposed current is transported by the noncracked part of the superconducting layer and the voltage is developed mostly in the cracked region in advance of development of
The portion (b) indicated in (a) is presented at high magnification in (b). (c) Ratio of $I_c(I_c)$ at $V=V_c$ to critical current $I_c$ and $I_{c0}$, showing that most of the current (more than 95%) is transferred by DyBCO layer at $I=I_{c0}$ in the wide range of $I_c$ values (20–195 A).

Voltage in the noncracked region. These results suggest that the relation of $I_c$ to $1-f$ is discussed.

C. Relation of critical current $I_c$ to the ratio $1-f$ of noncracked area and voltage probe distance $L$

The $1-f$ values obtained by fitting Eqs. (5) and (6) to the measured $V$-$I$ curves have been shown in Fig. 6(a). In order to examine whether the $I_c$ value is proportional to $1-f$ or not, the measured $I_c$ values are plotted against $1-f$, as shown in Fig. 10. The $I_c$ increases with increasing $1-f$, demonstrating that $1-f$ plays a dominant role in determination of $I_c$. However, the following inconsistency is found in Fig. 10. $I_c$ increases linearly with increasing $1-f$ up to around $1-f=0.7$. At $1-f=0.7$, $I_c$ reaches almost the nondamaged value. This means that, even though the cross-sectional area that transports superconducting current is reduced by 30%, the critical current of nondamaged state is retained. This inconsistency is overcome as follows, by incorporating the influence of sample length $L$ on $I_c$.

As shown in Sec V B. above, even under existence of crack, $I_c/I_{c0}$ is low (less than 0.05 in the wide range of $I_c$.

![Figure 8](image1.png)

**FIG. 8.** (a) An example of measured and analyzed $V$-$I$ curve and variation in shunting current $I_s$ with overall current $I$. The portion (b) indicated in (a) is presented at high magnification in (b). (c) Ratio of $I_c(I_c)$ at $V=V_c$ to critical current $I_c$ and $I_{c0}$, showing that most of the current (more than 95%) is transferred by DyBCO layer at $I=I_{c0}$ in the wide range of $I_c$ values (20–195 A).

![Figure 9](image2.png)

**FIG. 9.** (a) Examples of variation in overall voltage $V$ and voltage at cracked region $V_c$ with current $I$, from which the ratio $V_c/V$ at $I=I_c$ is read. (b) Variation in $V_c/V$ with critical current $I_c$, showing that the voltage stems from the cracked region in the wide range of $I_c$ values (20–180 A).

![Figure 10](image3.png)

**FIG. 10.** Critical current ($I_c$) values plotted against the ratio of noncracked area 1–f.
shown by \( V_s = V_c = 1 \) in wide range of \( I_c \) in Fig. 9(b). Therefore, the influence of \( L \) on \( V-I \) curve is very small under existence of crack; namely, \( V-I \) curve is practically determined by the cracked region regardless of value of \( L \). On the other hand, the critical current under a criterion of \( V_c = E_c L \) is dependent on \( L \); the larger the \( L \), the higher becomes \( I_c \) for a given \( V-I \) curve. Such a feature of dependence of \( I_c \) on \( L \) under existence of crack is expressed by Eq. (7).

The modified ratio \( (1-f)(L/s)^{1/n_0} \) of noncracked area, calculated with the \( 1-f \) values shown in Fig. 6(a), and \( L = 45 \) mm, \( s = 0.1 \) \( \mu \)m and \( n_0 = 39.6 \) which were used for obtaining \( 1-f \) values, is plotted against \( \varepsilon \) in Fig. 11(a). As the model used for analysis is constructed under the condition where \( I_c \) is reduced by cracking, \( I_c \) value under existence of crack is always lower than \( I_{c0} \) and hence \( (1-f)(L/s)^{1/n_0} \) ranges from zero to unity, never exceeding unity. As has been shown in Fig. 6(a), the \( 1-f \) drops suddenly from unity to around 0.7 when cracking occurs, which is reflected in the range of constant critical current for \( 1-f \approx 0.7 \) to 1.0 in Fig. 10. In contrast to the sudden drop in \( 1-f \) in Fig. 6(a), the modified ratio \( (1-f)(L/s)^{1/n_0} \) decreases gradually. Also the critical current under existence of crack is almost proportional to \( (1-f)(L/s)^{1/n_0} \), as shown in Fig. 11(b).

The result shown above means that, when cracking occurs very locally as in the present case, the \( V-I \) curve itself is determined almost by the very narrow cracked region whatever the value of \( L \) (=voltage probe distance/sample length) is, while the criterion \( V_c = E_c L \) for \( I_c \) is dependent on \( L \). In such a case, the modified ratio of noncracked area \( (1-f) \times (L/s)^{1/n_0} \) is a useful parameter for description of \( I_c \).

\section*{D. Influence of s-value on the result of analysis}

In the present work, \( s = 0.1 \) \( \mu \)m was used as similarly as in the preceding works for BSCCO and Nb\(_3\)Sn conductors.\(^{17,19,20}\) However, whether \( s = 0.1 \) \( \mu \)m is suitable for the present DyBCO conductor or not is not sure. In this subsection, the influence of \( s \)-value on the result of analysis is discussed below. It is shown that, even when \( s \)-value other than 0.1 \( \mu \)m is used, the analyzed results of \( V-I \) curve, \( I_c \), \( n \)-value, shunting behavior are the same as those obtained for \( s = 0.1 \) \( \mu \)m, while the value of \( 1-f \) becomes different, depending on \( s \)-value.

Equation (5) is rewritten in the following modified form:

\[ I = I_{c0}(1-f) \left( \frac{L}{s} \right)^{1/n_0} \left( \frac{V_s}{E_c L} \right)^{1/n_0} + \frac{V_s}{R_i}. \]  

(8)

In Eq. (8), only the expression is changed from that in Eq. (5), as to include the modified ratio of noncracked area \( (1-f)(L/s)^{1/n_0} \), whose values are shown in Fig. 11. Unknown parameters of \( 1-f, R_i, \) and \( s \) are included in Eq. (8). Among them, \( 1-f \) and \( s \) are expressed in the combined form of \( (1-f)(L/s)^{1/n_0} \) in Eq. (8). Namely, the \( V-I \) curve is determined by the two parameter values of \( (1-f)(L/s)^{1/n_0} \) and \( R_i \), not by the three parameters of \( 1-f, s, \) and \( R_i \). In the analysis in Secs. V A–V C above, we used a fixed value of \( s = 0.1 \) \( \mu \)m to estimate \( 1-f \) and \( R_i \) by curve-fitting with measured \( V-I \) curve. As \( 1-f \) and \( R_i \) are obtained as to best-fit the measured \( V-I \) curve for \( s = 0.1 \) \( \mu \)m, the \( (1-f)(L/s)^{1/n_0} \), calculated by the obtained \( 1-f \) and used \( s \)-value, and the obtained \( R_i \) also best-fit to the measured \( V-I \) curve. Even if other \( s \)-value \( (s \ll L) \) is used for analysis of a given \( V-I \) curve, the \( (1-f) \times (L/s)^{1/n_0} \) and \( R_i \) are the same since they are obtained as to best-fit to the \( V-I \) curve. Namely, though the \( 1-f \) and \( s \) are treated as separated values in the procedure, \( (1-f)(L/s)^{1/n_0} \) is determined uniquely regardless the \( s \)-value due to the nature of curve-fitting. Accordingly, the results obtained under a fixed \( s = 0.1 \) \( \mu \)m \( \{V-I\} \) curves (Fig. 4), resistance \( R_i \) [Fig. 6(b)], \( I_s \) [Fig. 7(a)], \( n \)-value [Fig. 7(b)], \( n-L_0 \) relation [Fig. 7(c)], \( I_c \) (Fig. 8), \( V_s \) (Fig. 9), and \( (1-f)(L/s)^{1/n_0} \) (Fig. 11) are retained for any \( s \)-value \( (s \ll L) \).

As stated above, due to the nature of curve-fitting, even if other \( s \)-value is used, the \( V-I \) curve can be reproduced and cracking-induced shunting behavior can be revealed by obtaining \( (1-f)(L/s)^{1/n_0} \) and \( R_i \). However, as long as \( s \)-value is unknown, \( 1-f \) cannot be obtained precisely. The influence of \( s \)-value on \( 1-f \) is examined below.

From the construction of Eqs. (8) and (6), \( 1-f \) varies with \( s \)-value. The \( 1-f \) values in Figs. 6(a) and 10 are valid only for \( s = 0.1 \) \( \mu \)m. If other \( s \)-value is used, different results are obtained. As \( (1-f)(L/s)^{1/n_0} \) is uniquely obtained, the influence of \( s \)-value on \( 1-f \) can be examined by substituting \( s \)-value and the known values of \( L = 45 \) mm and \( n_0 = 39.6 \) into \( (1-f)(L/s)^{1/n_0} \). For instance, for \( s = 1 \) \( \mu \)m (ten times larger than 0.1 \( \mu \)m) and 10 \( \mu \)m (100 times larger than 0.1 \( \mu \)m), \( 1-f \) values become larger by 1.06 and 1.12 times, respectively, in comparison with the \( 1-f \) value for \( s = 0.1 \) \( \mu \)m. Even if the used \( s \)-value is different by 100 times from 0.1 \( \mu \)m, the difference in \( 1-f \) is around 10%. Though \( 1-f \) value is dependent on \( s \)-value, it is not so sensitive to \( s \)-value.
VI. CONCLUSIONS

(1) The experimental results were analyzed with the model of Fang et al., in which the current shunting under existence of a crack is incorporated. In application, the arrayed multiple cracks was treated as a single equivalent crack. The experimentally measured variations in $V-I$ curve, critical current, and $n$-value with increasing applied strain and the correlation of $n$-value to critical current were described well by this model with replacement of multiple cracks by a single equivalent crack.

(2) At critical current under a criterion of $1 \mu V/cm$, most of the imposed current is transported by the noncracked part of the superconducting layer, and the voltage is developed mostly in the cracked region in advance of development of voltage in the noncracked region.

(3) Critical current under existence of partial crack decreases almost linearly with decreasing modified ratio of noncracked area to overall cross-sectional area of superconducting layer.

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